

# Electrodeposition of Indium from an Ionic Liquid Investigated by In Situ Electrochemical XPS

Zhen Liu <sup>\*</sup>, Jun Cheng, Oliver Höfft and Frank Endres <sup>\*</sup>

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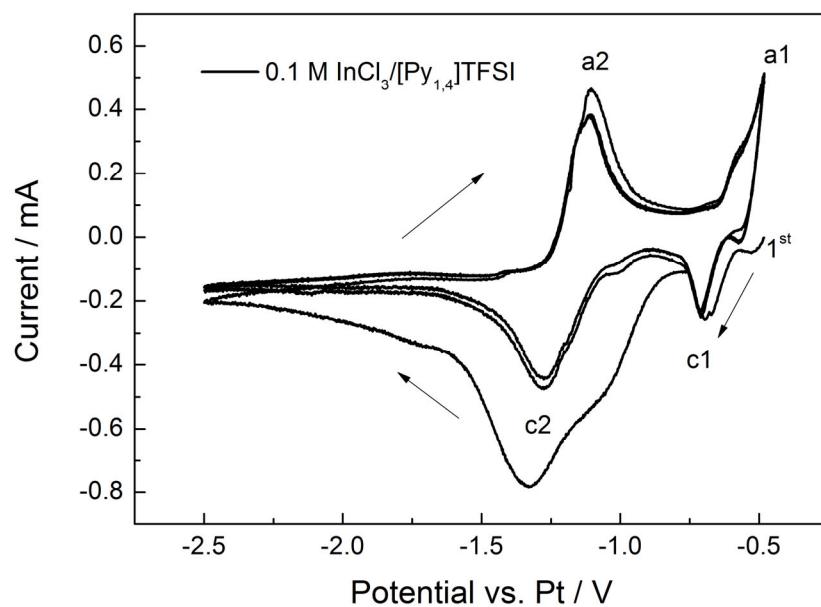
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Institute of Electrochemistry, Clausthal University of Technology, Arnold-Sommerfeld-Strasse 6, 38678 Clausthal-Zellerfeld, Germany; jun.cheng@tu-clausthal.de (J.C.); oliver.hoefft@tu-clausthal.de (O.H.)  
<sup>\*</sup> Correspondence: zhen.liu@tu-clausthal.de (Z.L.); frank.endres@tu-clausthal.de (F.E.)

## Supporting Information



**Figure S1.** CV of 0.1 mol/L  $\text{InCl}_3$  in  $[\text{Py}_{1,4}] \text{TFSI}$  in UHV on an Au electrode between  $-0.5$  V and  $-2.5$  V vs. quasi-Pt reference. Scan rate of  $10$  mV  $\text{s}^{-1}$ .